BeatMark Software to reduce the cost of x-ray mirrors (Stochastic Analysis of Surface Metrology data)

11-06-2018

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Supported by NASA SBIR-II NNX16CM09C









Overview

- 1. Our team and collaborators
- 2. Challenges in X-Ray mirror fabrication for Lynx X-Ray surveyor
- 3. What does the method solve?
- 4. Stochastic processes and InTILF analysis method
- 5. BeatMark software
- 6. 2D analysis method and 2D profile generation
- 7. Application to Polishing Optimization
- 8. Conclusions



Our Team has over 160 years combined experience in developing new mathematical methods into software

Research and Math



CEO and CTO



Anastasia Tyurina Prof. Yury Tyurin head of math development

Software team

Dr. Sergey Panov (Lead/physics)

Doug Paris (GUI)

Peter Panov (GUI/IT/ Platforms)





Business Development



Michael McComas (Proposals)



Chris Ilsley (Strategy)



IP and licensing



Michelle Freno (licensing) (IP)



Anna Ganelina









Jonathan Borowsky (WASHU)

Daniella Ganelin (MIT)

Jacob Panov (NHS)

Second Star SBIR-II NNX16CM09C

Second Star works with amazing collaborators



Polishing and metrology tools manufacturer



Dave Mohring (SBIR) Mike Bechtold (CEO)



Ed Fess (R&D head)

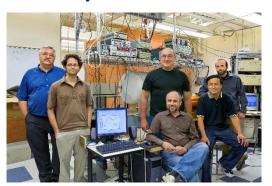


The best Metrology Lab in US





Dr Valeriy Yashchuk



Our collaborators think that if our technology works it will bring a revolution in polishing



Misha Gubarev

The project would not be where it is now without his expertize and support

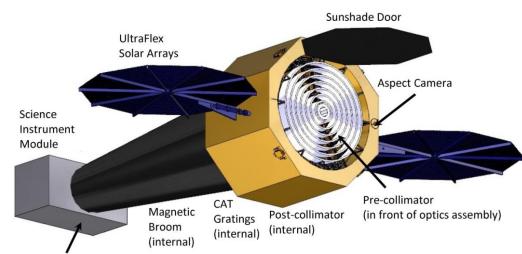




https://www.gofundme.com/mikhail-v-gubarevs-memorial

Objective of the project: To reduce fabrication cost of x-ray mirrors

Lynx - X-ray Surveyor Mission Concept*



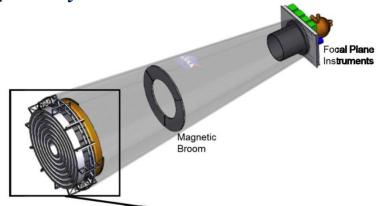
X-ray Microcalorimeter Imaging Spectrometer (XMIS) High Definition X-ray Imager (HDXI) CAT X-ray Grating Spectrometer (XGS) Readout

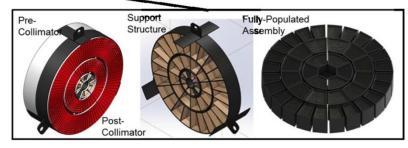
- 292-segmented shells nested into 42 individual mirror modules with overall size of 3 m outer diam.;
- ~ 0.2 arcsec root-mean-square (rms) slope error;
- \$600-1000 M estimated total cost of the mirrors

* J. A. Gaskin, M. C. Weisskopf, A. Vikhlinin, et. al., "The X-ray Surveyor Mission: A Concept Study," Proc. SPIE 9601, UV, X-Ray, and Gamma-Ray Space Instrumentation for Astronomy XIX, 96010J (August 24, 2015); doi:10.1117/12.2190837

The X-ray Surveyor requires X-ray mirrors to achieve large throughput with high angular resolution (0.5 arcsec) in order to avoid X-ray source confusion and background contamination.

High angular resolution is critical for providing unique identifications of faint X-ray sources.





X-ray Surveyor Telescope

What can our InTILF method do for X-ray mirror fabrication?

Yashchuk, V. V., Tyurin, Y. N., and Tyurina, A. Y., "Application of time-invariant linear filter approximation to parameterization of one- and two-dimensional surface metrology with high quality x-ray optics," Proc. SPIE 8848, 88480H-1-13 (2013).

Decrease Fabrication Cost

- Faster and easier fabrication through simplified and standardized quality control
- Polishing optimization
- Enable medium size mirror manufacturers to join the X-ray mirror market

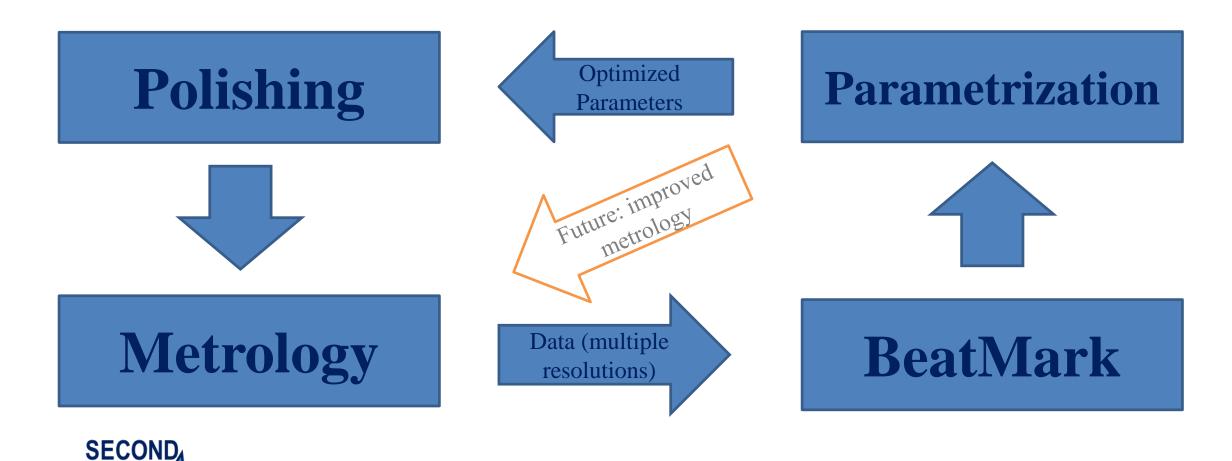
Increase Fabrication Speed

- Less metrology
- Less re-polishing

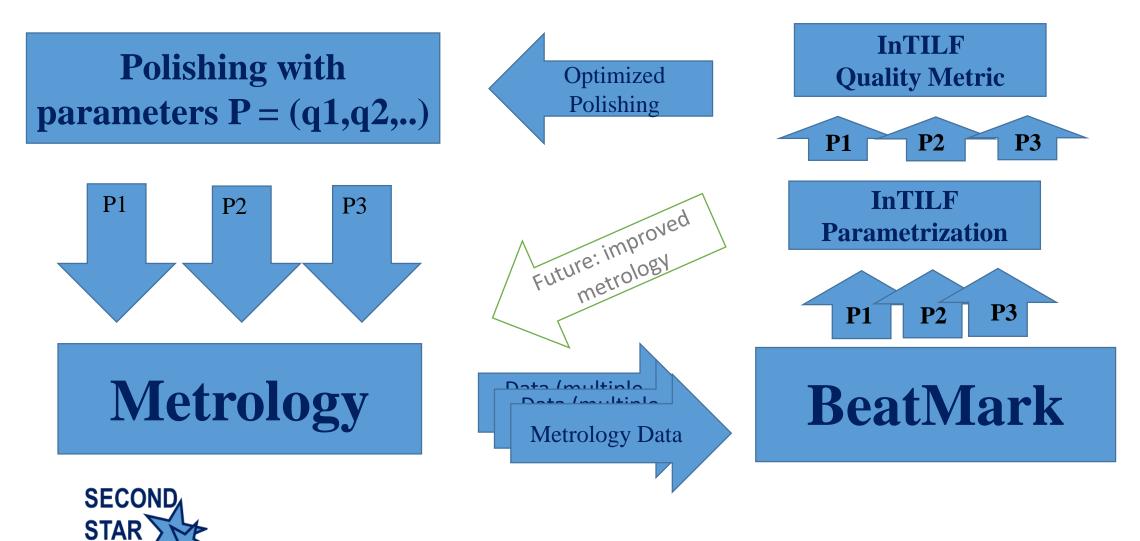
Increase Fabrication Predictability

- Metrics of quality and comparison of mirrors
- Generation of statistically equivalent metrology data
- Simulation of the X-ray mirror behavior within an X-ray optical system

BeatMark software package is developed to improve the iterative polishing and metrology process Step1: InTILF analysis



BeatMark concept step 2: Optimization of polishing and metrology process

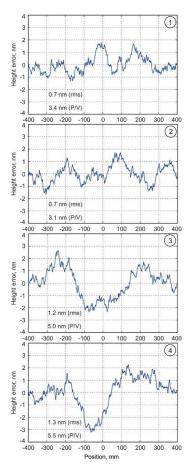


11/15/17

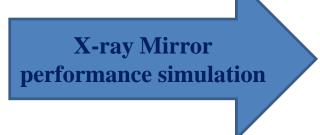
Patterns left on the mirror by polishing process are bad for imaging

Yashchuk, Samoylova, and Kozhevnikov: Specification of x-ray mirrors in terms of system performance (0pt Eng. 54-2-025108-2015)

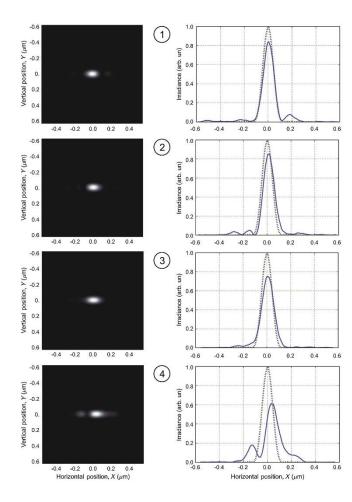
Simulated x-ray mirror profiles of the same surface height error rms



Simulated x-ray mirror imaging of a single point source (left) and its cross sections (right)



It is not just rms!





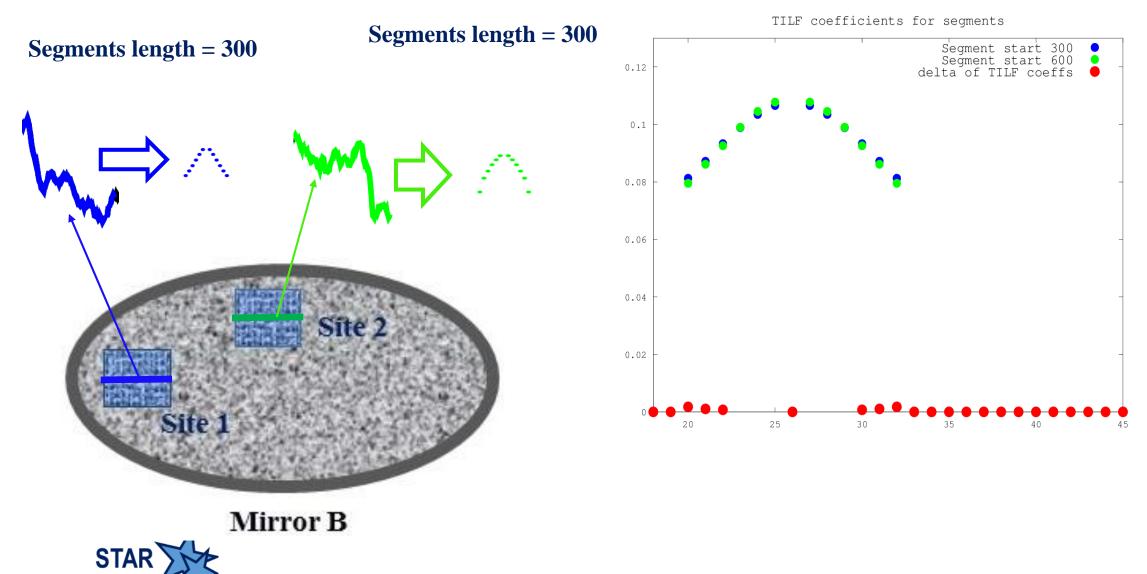
Logic of the project

- Periodic process spectral characteristics (aka correlations) are surmised by Fourier transform
- Stochastic process spectral characteristics (aka correlations) are surmised with statistical tools
- We think we can optimize the polishing and metrology process because we learned to characterize stochastic surface data with

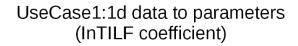
Invertible Time Invariant Linear Filters (InTILF)

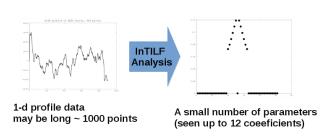


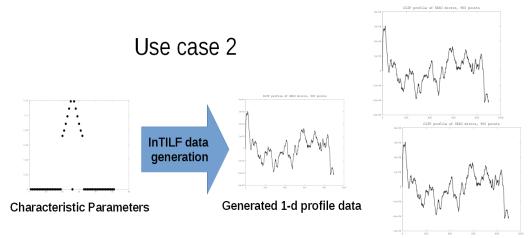
InTILF method provides characterization of the surface based on small metrology samples



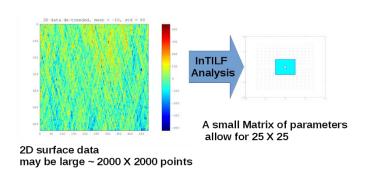
BeatMark prototype software

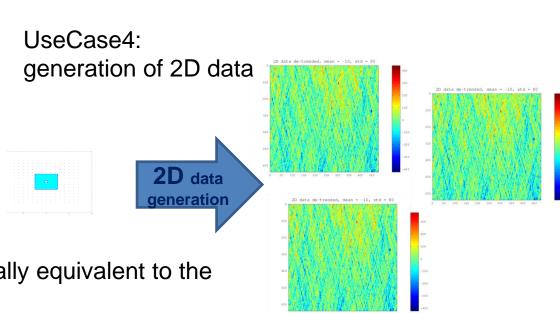






UseCase3: 2D data to parameter Matrix

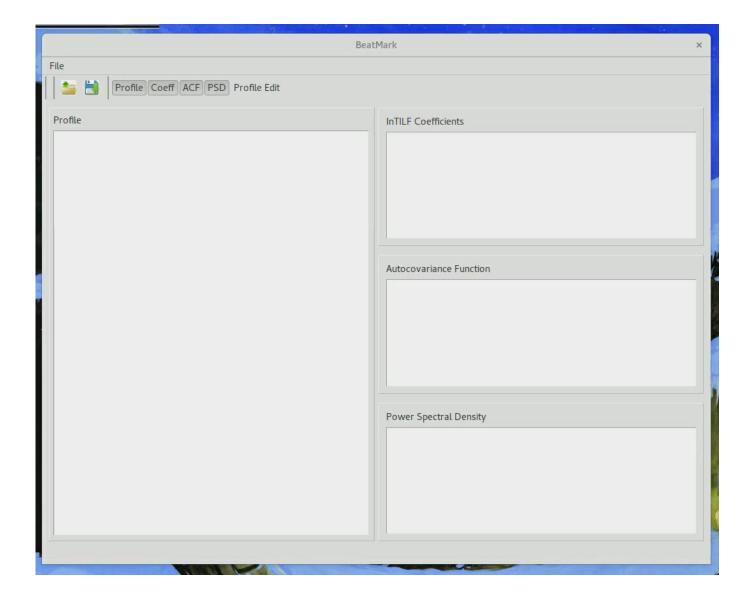






Generated Data is statistically equivalent to the original data

BeatMark prototype demo





BeatMark software is the first to provide:

- statistical analysis of 2D metrology profiles (surface)
- generates 2D profiles statistically equivalent to a given 2D profile



Projects status

1) Software development

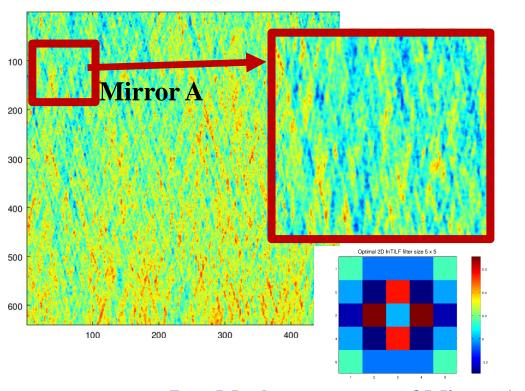
- 1D application commercial prototype is ready
- 2D application developed for finding InTILF models
- 2D surfaces generation
- Format readers, a few developed, ongoing

2) Application to polishing

- OptiPro completed two polishing data collections
- LBNL received re-measured one set of samples is re-measuring the other
- Second Star is analyzed the first data collection the results will be presented
- The team is discussing the analysis of the second data collect

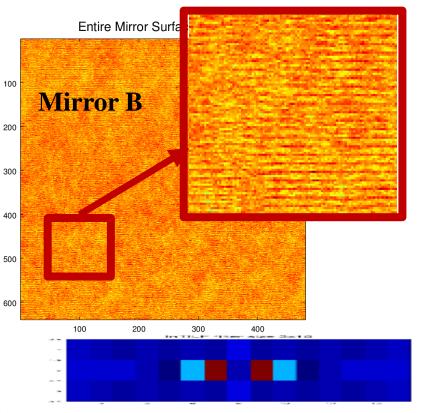


BeatMark-2D analysis



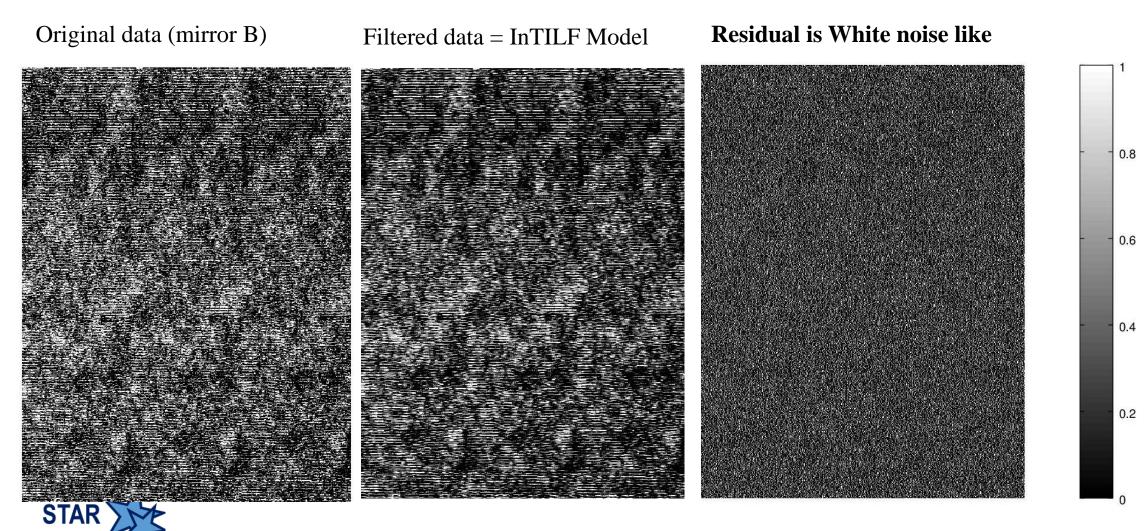
BeatMark assessment of Mirror A: InTILF 5x5 matrix Residual < 1 %



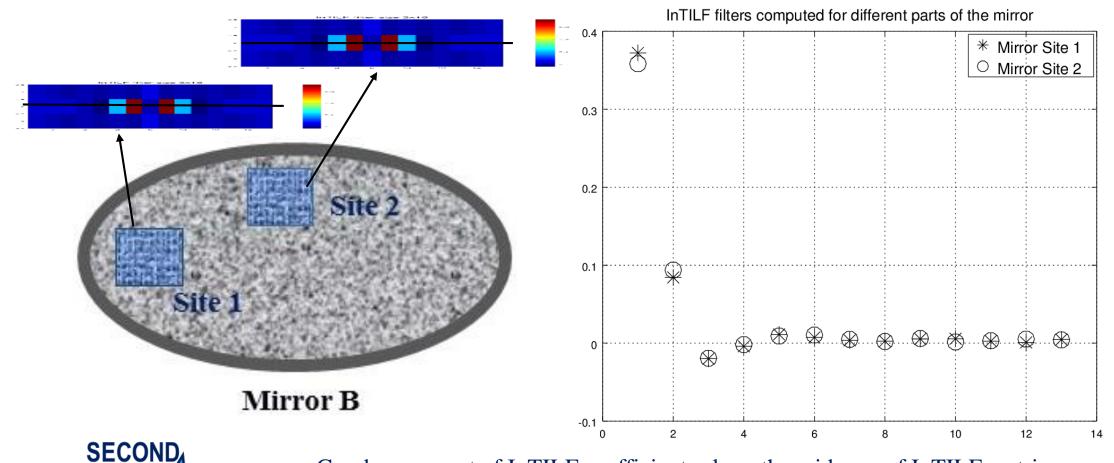


BeatMark assessment of Mirror B: InTILF = 3 x15 matrix Residual = 23%

2D InTILF analysis of Mirror B



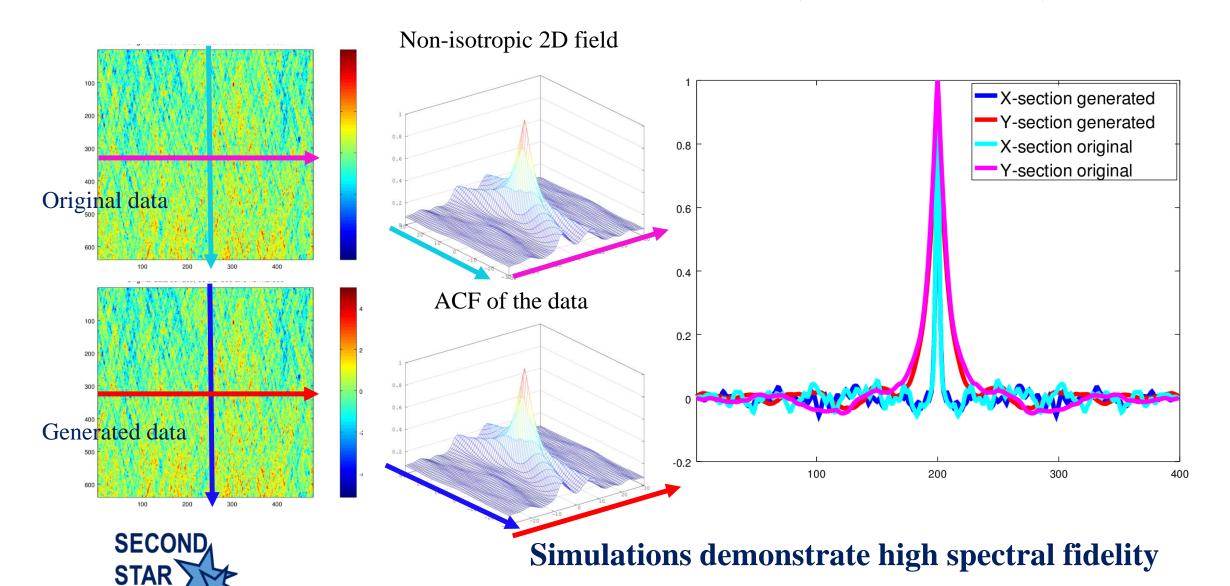
2D InTILF analysis is stable along the mirror



STAR

Good agreement of InTILF coefficients along the mid-row of InTILF matrices computed for metrology data from Site 1 and Site 2. The difference is < 3.5% value

Generation of 2D InTILF model (use case 4)



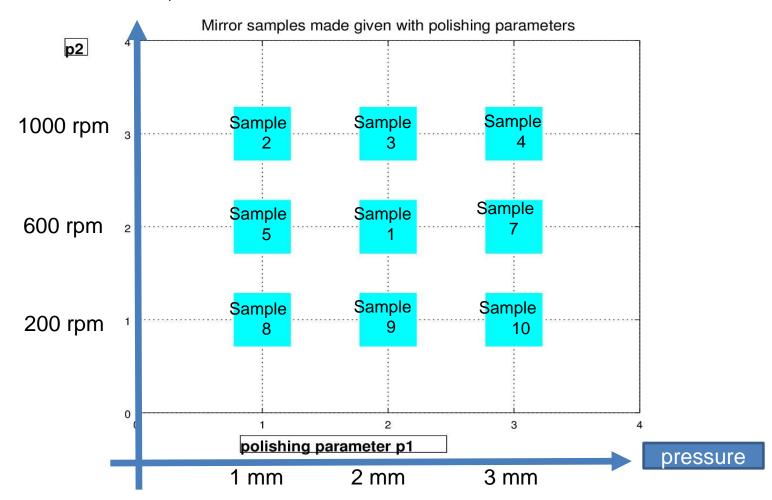
Application of BeatMark to Polishing Optimization (BeatMark step 2, slide 9)

Data Collection 1:

10 Samples Polished with different polishing parameters

Two polishing parameters:

- **speed** (in rpm) and
- **pressure** (in mm) were varied around perceived optimal values of
- 600 rpm
- 2 mm.





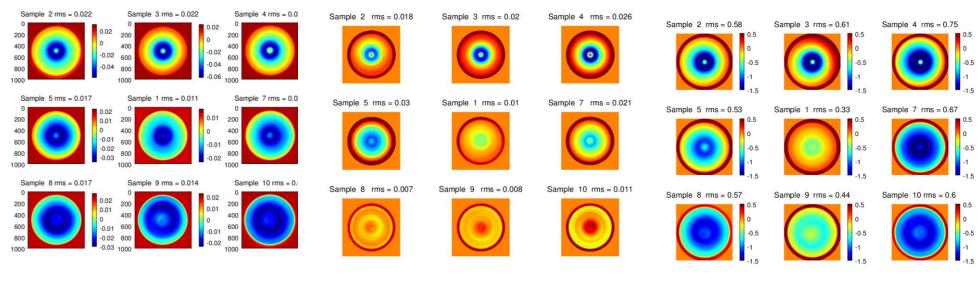
Second Star 21

Samples were measured with different instruments

Instrument	Measured by	Dimension – 1D or 2D
Interferometer	OptiPro	2
UltraSurf	OptiPro	2
Profilometer	OptiPro	1
New View	OptiPro	2 (at higher resolution)
Interferometer	LBNL	2



Samples measured by different Instruments

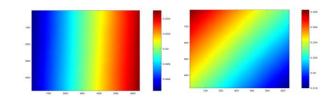


OptiPro Interferometer

OptiPro UltraSurf

LBNL Interferometer

For the rough analysis that we did in this first experiment we saw no material differences in analysis results. This will have to be monitored when we progress toward finer experiments.



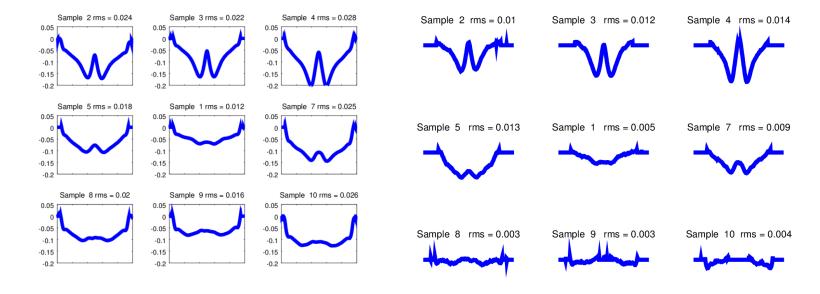
OptiPro NewView



1D profiles for all instruments

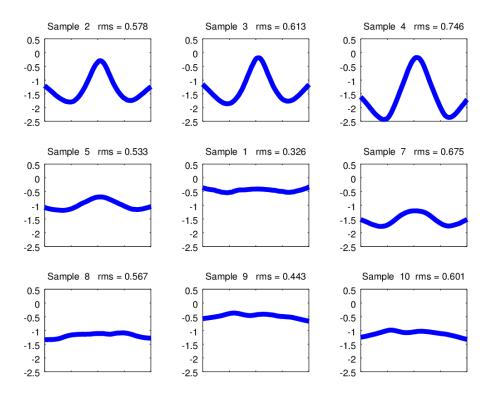
OptiPro Interferometer

OptiPro UltraSurf





All Sections as measured by LBNL



Mirror Height

Pixels 1- 600

These are sections of the mirror samples (we checked that they are uniform about the angle)

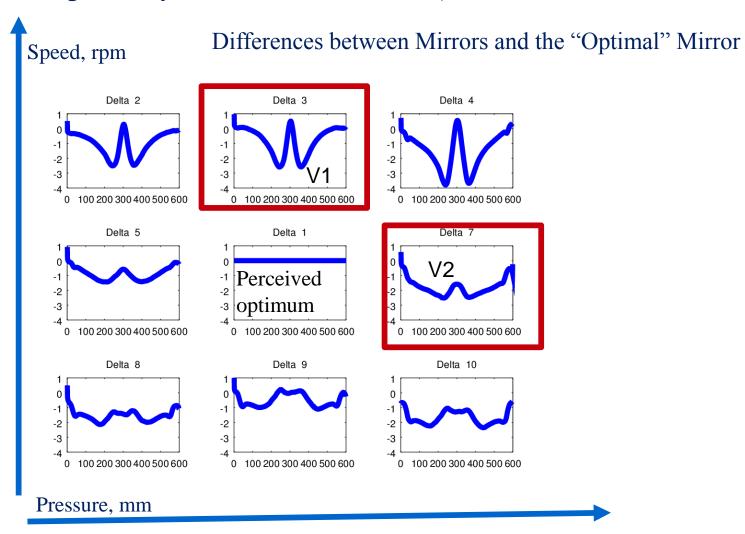


Two methods of mirror quality comparison

- Shape analysis (large effects)
- Stochastic analysis (finer effects)



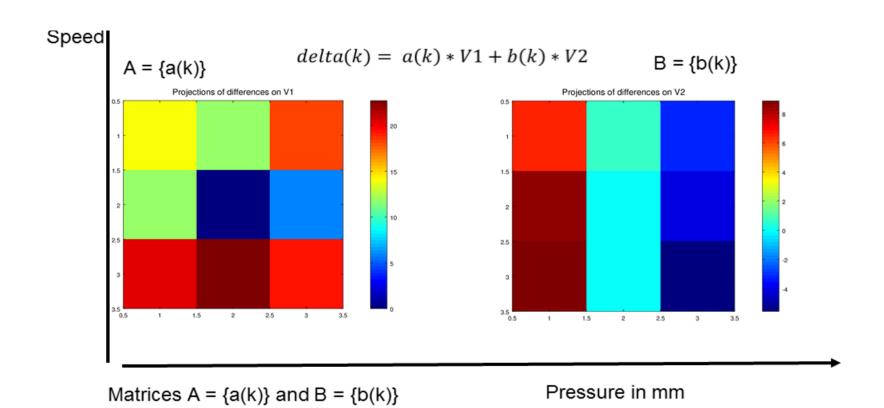
Method 1: Sape analysis. "Basic" vectors (aka Characteristic vectors)





Express all other differences deltas as "vectors" in the space of functions as a linear combination of "vectors" V1 and V2:

Method 1: Vector decomposition with basic vectors



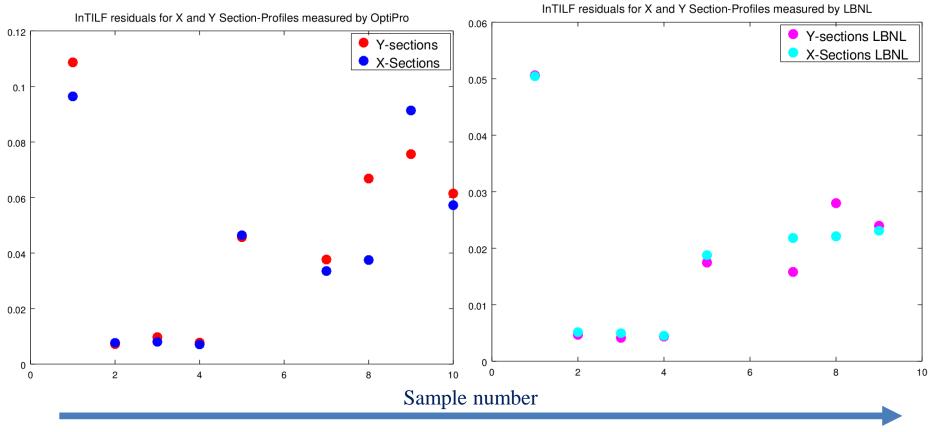
Method 1 shows good potential in optimizing for polishing parameter 'pressure'.



The dependence of a sample shape on pressure appears "linear" in its magnitude. Not so for the rotation speed.

Method 2: InTILF-Quality indicator computed for OptiPro and LBNL data

Quality Indicator, based on InTILF was computed for samples using good quality central segments

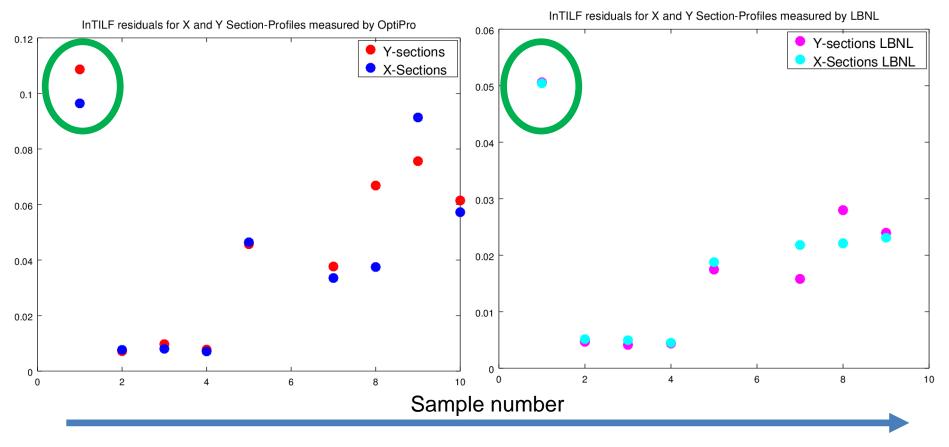




The data is numerically different (for sample measurement errors related issues), but qualitatively points to the same optimal sample 1

Method 2: InTILF-Quality indicator computed for OptiPro and LBNL data

Quality Indicator, based on InTILF was computed for samples using good quality central segments



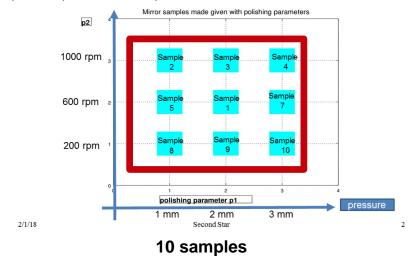


The data is numerically different (for sample size related normalization issues), but qualitatively points to the same optimal sample 1

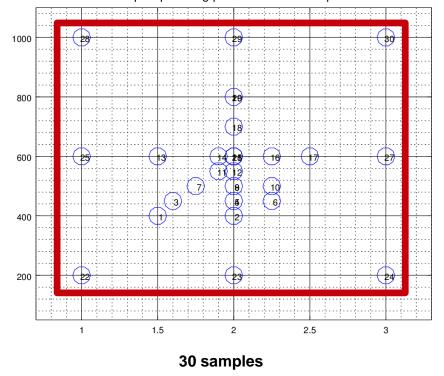
Design of data collection 2

Recall experiment 1:Samples Polished with different polishing parameters

Two parameters: **speed** (in rpm) and **pressure** (in mm) were varied around perceived optimal values of 600 rpm and 2 mm.



Test 2 samples polishing parameters and sample numbers



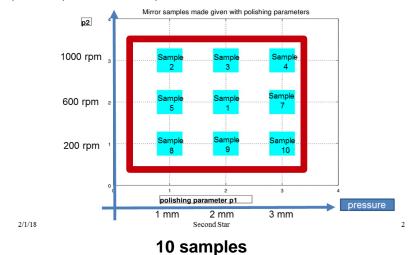


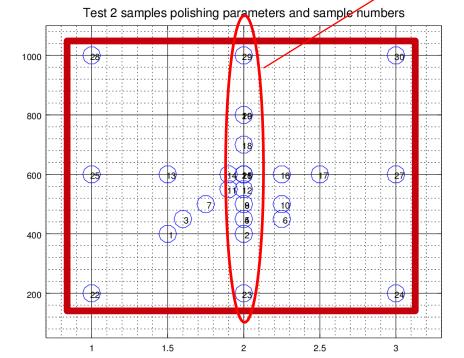
Design of data collection 2

To study non-linear dependence on speed

Recall experiment 1:Samples Polished with different polishing parameters

Two parameters: **speed** (in rpm) and **pressure** (in mm) were varied around perceived optimal values of 600 rpm and 2 mm.





30 samples



Conclusions:

BeatMark software package – the prototype implementation of InTILF

- characterizes mirror surfaces with a small number of parameters
- needs only modest amount of metrology data to characterize the entire surface
- generates **simulated 'metrology' profiles** statistically equivalent to the original profile (1D or 2D)

We are working on using the BeatMark (and InTILF) to:

- provide the surface quality assessment through a quality metric
- look to work on validation of q-metrics with XFEL
- lead to significant improvements in polishing

Possible development of InTILF method may lead to comprehensive analysis of metrology data taken by instruments with different Modulation Transfer Function.



Acknowledgments

This work was supported by NASA Small Business Innovation Research SBIR grant to Second Star Algonumerix, project No. 15-1 S2.04-9193. The Advanced Light Source is supported by the Director, Office of Science, Office of Basic Energy Sciences, Material Science Division, of the U.S. Department of Energy under Contract No. DE-AC02-05CH11231 at Lawrence Berkeley National Laboratory.



Thank you for your attention!



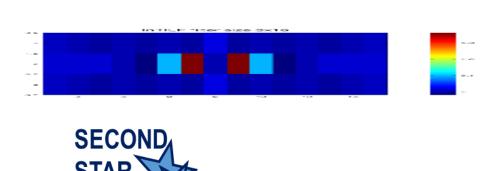
Appendix

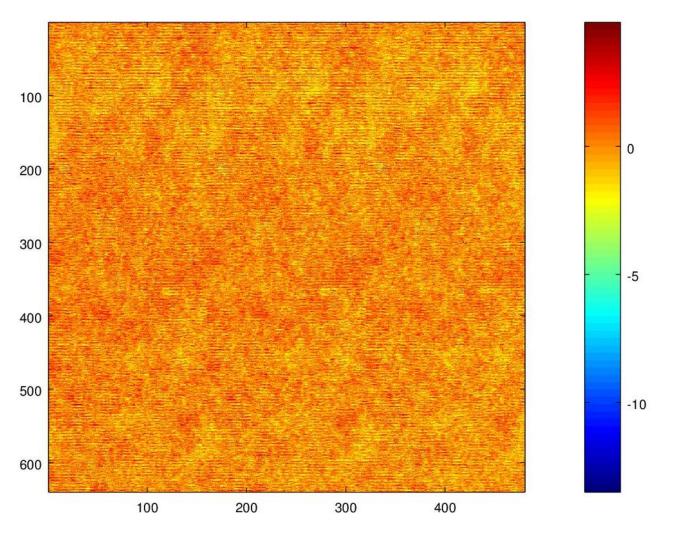


InTILF analysis of mirror B

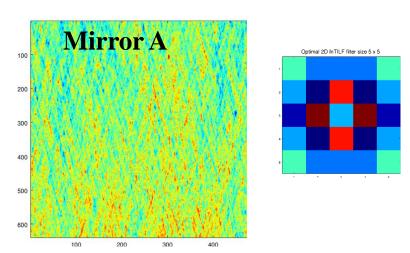
Height distribution of the mirror B measured with the ALS XROL interferometric microscope ZYGO NewViewTM-7300 equipped with 2.5× objective with $\times 2.0$ zoom surface area 1.06 mm \times 1.41 mm effective pixel size of 2.2 μ m (640 pixels \times 480 pixels) Measured surface topography has a structure of horizontal 'strips' with rms variation of the surface height of 1.74 Å.

InTILF matrix 3 x 15

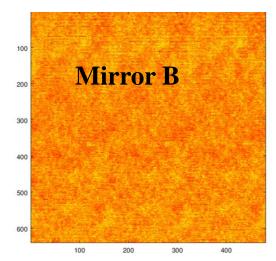


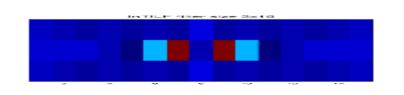


BeatMark-2D assessment of two mirrors



BeatMark assessment of Mirror A: InTILF 5x5 matrix Residual < 1 %





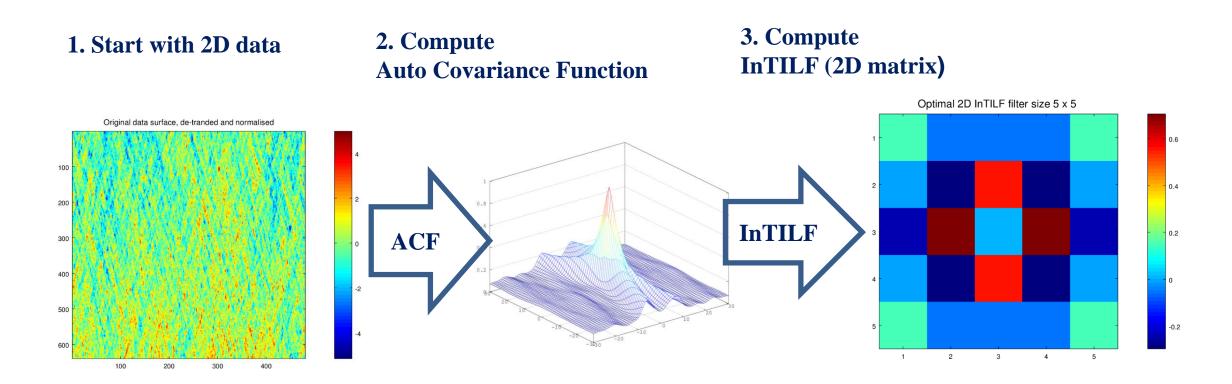
BeatMark assessment of Mirror B: InTILF = 3 x15 matrix Residual = 23%

How many parameters do fully describe a mirror?

A: 25 B: 45



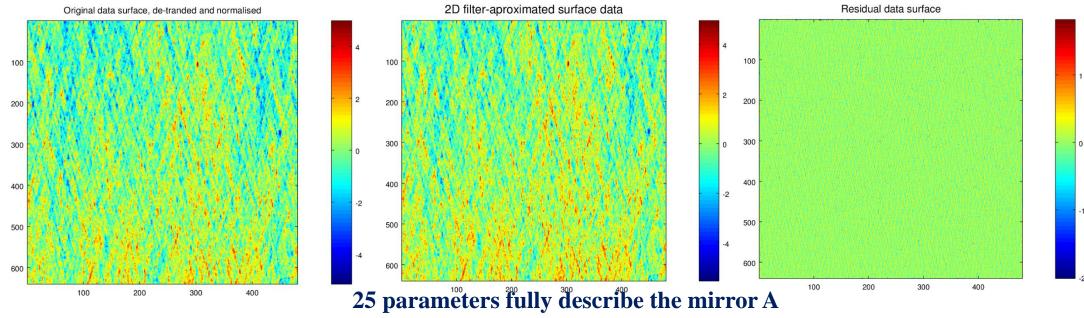
Construction of 2D InTILF model, mirror A





2D InTILF analysis of Mirror A

Mirror A data: height distribution measured with an interferometric microscope ZYGO NewViewTM-7300 equipped with 2.5× objective with $\times 2.0$ zoom. The Microscope is available at the ALS XROL. ^{18,19} The left-hand plot in Fig. 1 shows the rectangular surface area of 1.06 mm \times 1.41 mm measured with the effective pixel size of 2.2 μ m (the data set consists of 640 \times 480 pixels²). The measured surface topography has a characteristic 'diamond' like pattern with rms variation of the surface height of 6.75Å.





2D InTILF model accuracy: residual rms ~1%

Stationary Random Process (SRP) and its Auto-covariance function (ACF) in 2D

Natural extension to 2D:

SPR:
$$x(t_1, t_2)$$
: $Z^2 -> R^2$ & $E(X(t_1 + h_1, t_2 + h_2) * X(t_1, t_2)) = E(x(h_1, h_2)X(0)), \forall h = (h_1, h_2) => introduce ACF $Q_x(h) = Q_x(h_1, h_2) = E\{x(t_1 + h_1, t_2 + h_2)x(t_1, t_2)\}.$$

In 2D b) means that for any natural number m, any m integers h_1, \dots, h_m and any real numbers $z_{1,\dots}, z_m$

$$\sum_{i,j=1}^{m} q(h_i - h_j) z_i z_j \geqslant 0$$

ACF Q(.,.) of a stationary random process on a lattice \mathbb{Z}^2 can be represented as:

$$q(h_1,h_2) = \int_{-\pi}^{\pi} \int_{-\pi}^{\pi} e^{ih_1x_1 + ih_2x_2} \mu(dx_1,dx_2), (h_1,h_2) \in \mathbb{Z}^2$$



Polishing optimization idea

- Ideal mirror surface deviates from its form very slightly and in an absolutely random manner white noise random
- White noise is an absolutely random process completely devoid of pattern
- A polishing tool might leave a pattern (correlations) on a mirror. If it is detected and characterized, the mirror can be improved by optimizing polishing parameters.
- Our task is to detect and characterize the pattern

We are in search of the stochastic pattern

